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Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

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- (presently amended) A metallic glass alloy of the formula XaCuoNioAldYe wherein 1. X-comprises at least one element from Group IVA Hf₀Cu_bNi_cAl₀Y_c wherein;
- Y comprises at least one element from Group VA, VIII, IVB, VB, or Group IVA, wherein X is not equal to Y IVA, IVB, VA, or VB;
 - a is less than 45 atomic percent;
 - b is from about 15 to about 35 atomic percent;
 - c is from about 5 to about 25 atomic percent;
 - d is from about 0.10 to about 20 atomic percent; and
 - e is from about 0.10 to about 15 atomic percent, wherein a+b+c+d+e=100.
- 2. (previously presented) The metallic glass alloy of claim 1, wherein a is 44.5 atomic percent or less.
- 3. (presently amended) The metallic glass alloy of claim 2, wherein X is Hf, Zr, or Sn and Y is Ti or Nb.
- (previously presented) The metallic glass alloy of claim 1, further comprising a density 4. greater than about 7 g/cm³.
- 5. (previously presented) The metallic glass alloy of claim 4, wherein the density is about 10.5 g/cm³ or more.
- (previously presented) The metallic glass alloy of claim 1, wherein the alloy exhibits a 6. distinct glass transition temperature, which is at least 0.59 of the liquidus temperature of the alloy.

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(presently amended) The metallic glass alloy of claim 1, wherein the ratio of eopper to 7. nickel Cu to Ni is 2:1.

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- 8. (presently amended) The metallic glass alloy of claim 3, wherein the ratio of eopper to niekel Cu to Ni is 2:1.
- (previously presented) The metallic glass alloy of claim 3, having about 5 or more atomic 9. percent Ti.
- (previously presented) The metallic glass alloy of claim 3, having about 5 or more atomic 10. percent Nb.
- 11. (previously presented) The metallic glass alloy of claim 1, wherein d is about 10 or more.
- 12. (presently amended) The metallic glass alloy of claim 1, wherein 35<a<45, 15<b<35; 5<e<25, 0<d<20, and 0<e<15 0.1<d<20, and 0.1<e<15.
- 13. (previously presented) An article comprising the metallic glass alloy of claim 1.
- 14. (previously presented) The article of claim 13 having a thickness of at least 1 millimeter in its smallest dimension.
- 15. (previously presented) The article of claim 13 having a thickness at least 3 millimeters in its smallest dimension.
- 16. (previously presented) A metallic glass alloy composition comprising: 44.5 atomic percent hafnium; about 27 atomic percent copper;

about 13.5 atomic percent nickel; about 10 atomic percent aluminum; and about 5 atomic percent titanium or niobium.

- 17. (previously presented) The composition of claim 16 having a density greater than 7 g/cm³.
- 18. (previously presented) The composition of claim 16, having a density of about 10.9 g/cm³ or more.
- 19. (previously presented) The composition of claim 16, wherein the composition exhibits a distinct glass transition temperature of at least 0.59 of the liquidus temperature of the composition.
- 20. (previously presented) An article comprising the metallic glass alloy of claim 16.
- 21. (previously presented) The article of claim 20 having a thickness of at least 1 millimeter in its smallest dimension.
- 22. (previously presented) The article of claim 20 having a thickness of at least 3 millimeters in its smallest dimension.
- 23. (previously presented) The article of claim 20, wherein the ratio of copper to nickel is 2:1.
- 24. (presently amended) The article of claim 20, wherein the metallic glass is at least partially erystalline amorphous.

- 25. (previously presented) The article of claim 20, wherein the article has an elastic strain to failure between about 1.8 and 2.2 percent elongation.
- 26. (previously presented) The article of claim 20, wherein the object has a quasi-static compressive yield stress of between about 1.8 and 2.2 GPa.
- 27. (previously presented) The article of claim 20, wherein the object has a dynamic high-strain-rate yield stress of between about 1.3 and 1.6 GPa.
- 28. (previously presented) A metallic glass alloy comprising Hf, Cu, and Ni in eutectic combination with Al, Ti, Nb or a combination thereof, having a density greater than about 7 g/cm³.
- 29. (previously presented) A method for forming a metallic glass alloy comprising: combining 44.5 atomic percent hafnium; about 27 atomic percent copper; about 13.5 atomic percent nickel; about 10 atomic percent aluminum; and about 5 atomic percent titanium or niobium.
- 30. (previously presented) The metallic glass alloy of claim 1, wherein the alloy is formed by electric arc melting.
- 31. (previously presented) The metallic glass alloy of claim 1, wherein the alloy is formed by induction melting.
- 32. (previously presented) The article of claim 16, wherein the article is formed by vacuum suction casting.
- 33. (previously presented) The article of claim 16, wherein the article is formed by permanent mold casting, injection die casting, pour casting, planar flow casting, melt spinning, or extrusion.

- 34. (previously presented) A method for making an alloy, comprising: eutectically combining Hf, Cu, and Ni with Al, Ti, Nb or a combination thereof, to form a metallic glass alloy having a density greater than about 7 g/cm³.
- 35. (new) An alloy comprising Hf, Cu, and Ni in an invariant combination.
- 36. (new) The alloy of Claim 35 in eutectic combination with Al.
- 37. (new) The alloy of Claim 36 in eutectic combination with Ti and Nb or a combination thereof.
- 38. (new) The alloy of Claim 35 in eutectic combination with an element from Group IVA or Group IVB.
- 39. (new) The alloy of Claim 36 in eutectic combination with an element from Group IVA or Group IVB.